TS Workshop 2004

## Vacuum chambers for LHC LSS

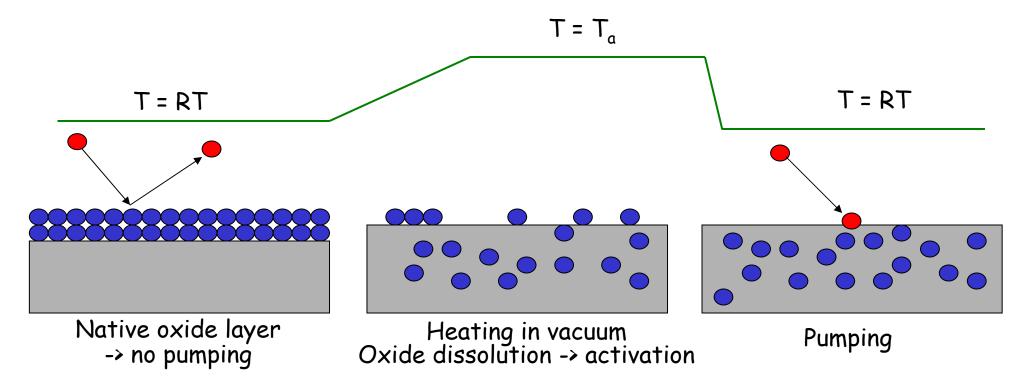
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- The LHC Long Straight Sections (LSS), operating at room temperature, are interposed between the cryogenic modules of the LHC.
- The NEG materials, developed at CERN, will assure the main pumping of the LSS vacuum system.
- NEG films were chosen for their benefical characteristics: high distributed pumping speed, low static and dynamic degassing and low secondary electron yield.

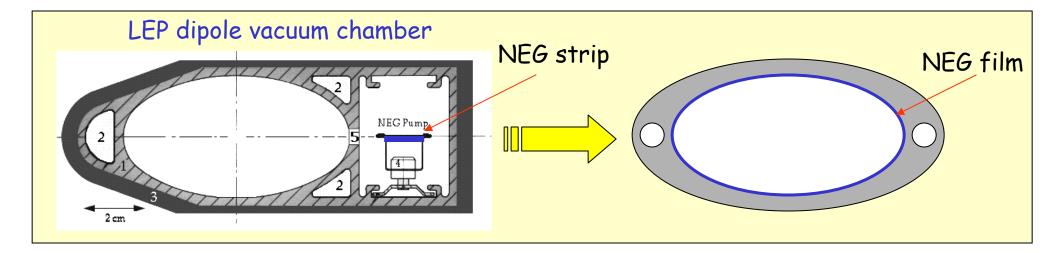
Getters are materials capable of chemically adsorbing gas molecules. To do so their surface must be clean. For <u>N</u>on-<u>E</u>vaporable <u>G</u>etters a clean surface is obtained by heating to a temperature high enough to dissolve the native oxide layer into the bulk.



NEGs pump most of the gas except rare gases and methane at room temperature

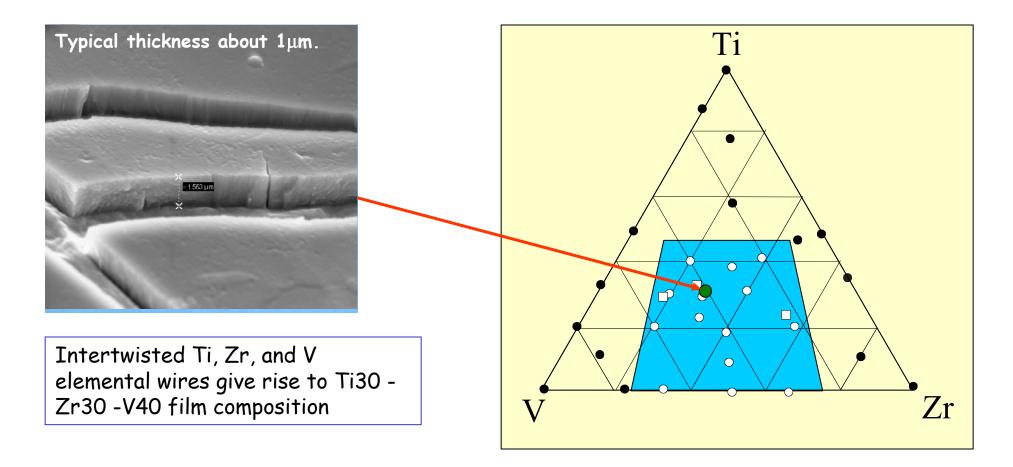
NEG strips (st101 and st707) were already used to assure linear pumping speed in LEP. It requires electrical insulators and feedthroughs, limiting the pumping speed that can be installed in the chamber.

Coating the inner surface of the vacuum chamber with a NEG film transforms it from a source of gas into a pump.

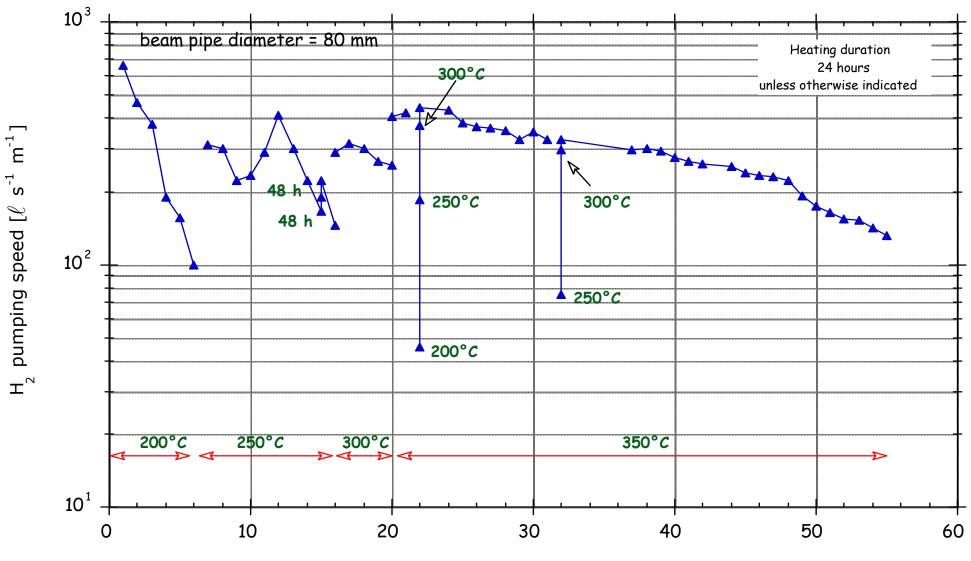


To be compatible with the structural materials of the vacuum chambers, NEG film should allow a complete dissolution of the oxide layer at a reasonable low temperature.

The lowest activation temperature was found in a wide range of composition in the Ti-Zr-V system: 180 °C (24 h heating).



TiZrV coating performances: ageing

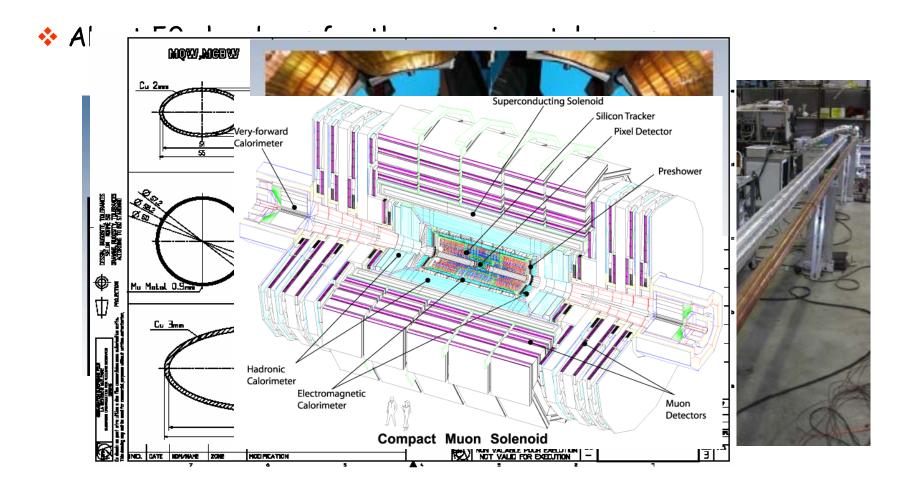


Number of heating/venting cycles

6

✤ 675 LSS drift space chambers: Ø 80 mm, L=0.3m ~ 7m (work-package attributed to the EST division)

About 285 non-standard LSS chambers for the warm magnets



## Overview of the fabrication of the LSS drift space chambers:

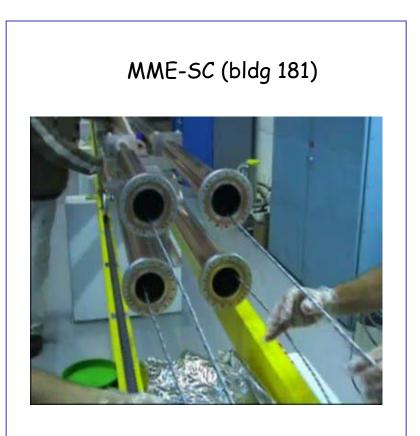
The two stainless steel flanges are each vacuum brazed to a OFE Cu stub

Welding of the flange/Cu stub assemblies to the OFS Cu tube

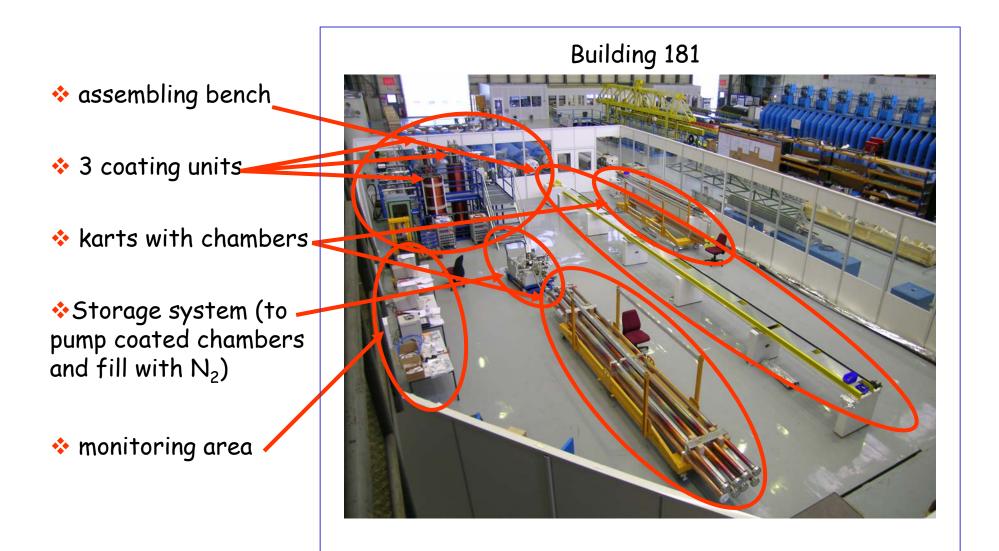
Leak test

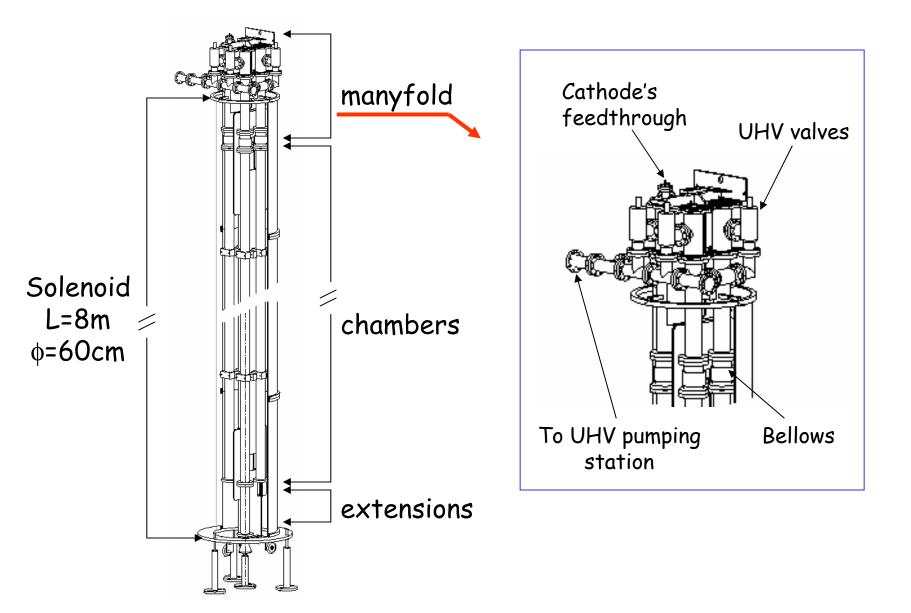
Surface treatment: degreasing, etching 70µm and passivation of the surface

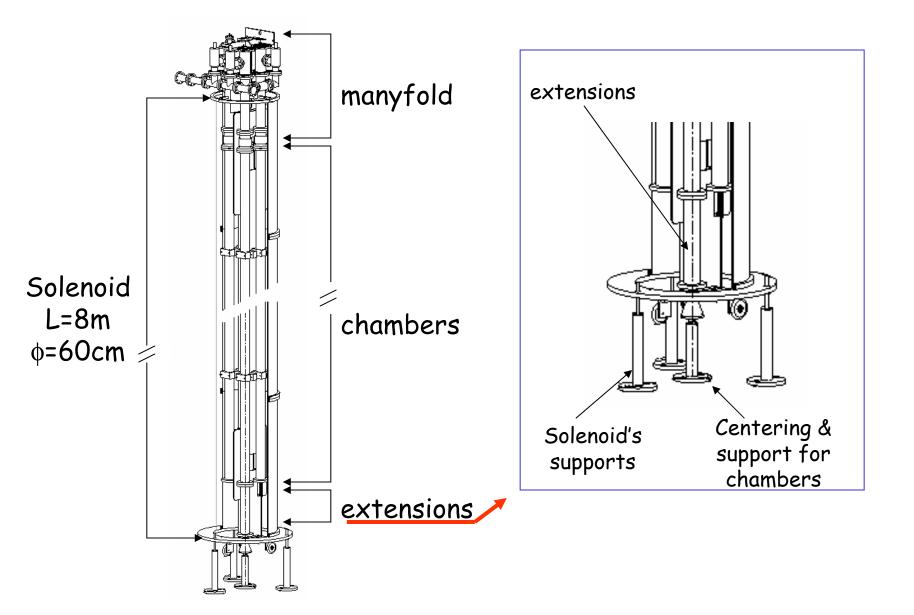
NEG coating by DC magnetron sputtering



## The NEG coating facilities

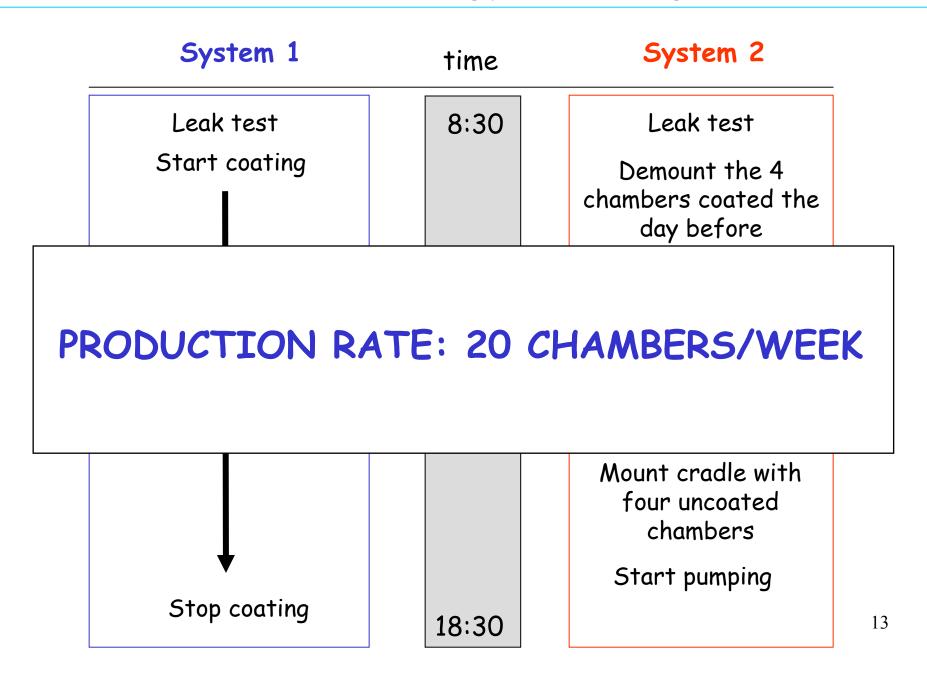






- Discharge gas Pressure -> 4x10-3 Torr Supply atoms for the ionization process. Potential U -> -500 V Defines the energy of the ions. ♦ Current I -> 15 A Defines the rate of the ions hitting the cathode. ✤ Magnetic field -> 150 G Increase the ionization efficiency improving stability and allowing lower discharge pressure Noble gas. Kr chosen in order to minimize the Discharge gas -> Kr discharge gas trapping in the coating.
- \* Deposition rate -> 0.2  $\mu$ m/h => 10h for a 2 $\mu$ m coating

## LSS NEG coating production timing



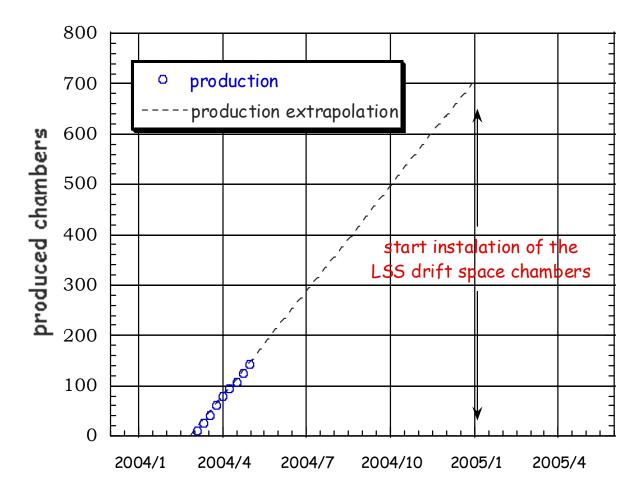
- Before coating: Visual inspection of the internal surface of each chamber;
- During coating: Leak detection: mass spectra before and after coating and monitoring mass 20 (Ar\*\*) to detect an eventual leak during the coating process.
  Monitoring of the discharge parameters (I,V,P);

After coating: Visual inspection of the coating

Whitness samples:

- ✓ 10×15mm<sup>2</sup> to measure coating thickness by SEM, composition by EDX and activation by XPS.
- 25 cm long chambers for pumping speed measurements
  (2 per week)
- ✓ Every month one chamber is fully characterized (pumping speed, surface capacity, CH<sub>4</sub> and Kr outgassing)

In 9 weeks, 142 chambers were coated, representing 21.5% of the total production.



At the actual rate, the production will be completed by beginning 2005.

